

What is claimed is:

1 1. A semiconductor device comprising:
2 a thyristor having thyristor body regions including first and second immediately
3 adjacent base regions between first and second emitter regions;
4 a first control port configured and arranged to capacitively couple a first signal at least
5 to the first base region; and
6 a second control port configured and arranged for coupling a second signal at least to
7 the second base region, the second signal being adapted to control holding current or forward
8 blocking voltage of the thyristor as a function of temperature.

1 2. The semiconductor device of claim 1, further comprising:
2 a circuit arrangement electrically coupled to the second control port and configured and
3 arranged to apply the second signal to the second control port.

1 3. The semiconductor device of claim 2, wherein the circuit arrangement includes a
2 temperature sensing circuit electrically coupled to the thyristor and configured and arranged to
3 apply the second signal to the second control port as a function of the temperature of the
4 thyristor.

1 4. The semiconductor device of claim 2, wherein the second signal applied by the
2 temperature sensing circuit is adapted to increase bipolar gains of the thyristor when the
3 temperature of the thyristor is below a selected threshold.

1 5. The semiconductor device of claim 4, wherein the selected threshold is a temperature at
2 which the holding current of the thyristor would exceed a design holding current value.

1 6. A memory device comprising:
2 at least one thyristor having thyristor body regions including first and second
3 immediately adjacent base regions respectively coupled to and between first and second
4 emitter regions;

5 a first control port configured and arranged to capacitively couple a first signal at least
6 to the first base region;

7 a first circuit configured and arranged to detect a temperature-related failure of the
8 thyristor to maintain its conductance state during a standby mode or to maintain its blocking
9 state; and

10 a second circuit including a second control port configured and arranged for coupling a
11 second signal at least to the second base region as a function of the detected failure for
12 controlling holding current or forward blocking voltage of the thyristor.

1 7. The memory device of claim 6, further comprising a reference thyristor, the first circuit
2 being configured and arranged to detect the failure condition from the reference thyristor.

1 8. The memory device of claim 7, wherein the reference thyristor is configured and
2 arranged to exhibit temperature-responsive failure prior to the at least one thyristor as the
3 operating temperature of the memory device varies from a design operating temperature
4 thereof.

1 9. The memory device of claim 8, wherein the reference thyristor is configured and
2 arranged to fail at a lower temperature than the at least one thyristor as the operating
3 temperature increases above the design operating temperature.

1 10. The memory device of claim 8, wherein the reference thyristor is configured and
2 arranged to fail at a higher temperature than the at least one thyristor as the operating
3 temperature decreases below the design operating temperature.

1 11. The memory device of claim 6, further comprising a plurality of memory cells, each
2 memory cell including a thyristor, wherein the first circuit further comprises:

3 a first reference memory cell including a thyristor and adapted to store a data “zero”
4 and to fail to retain the data “zero” as a function of the conductance state of the thyristor in the
5 first reference memory cell before other memory cells in the memory device fail data “zero”;

6 a second reference memory cell including a thyristor and adapted to store a data “one”
7 and to fail to retain the data “one” as a function of the conductance state of the thyristor in the
8 second reference memory cell before other memory cells in the memory device fail data “one”;
9 and

10 the second circuit being adapted to apply the second signal to the second control port as
11 a function of at least one of the first and second reference memory cells failing to retain data.

1 12. The memory device of claim 11, wherein an emitter of the thyristor in the first
2 reference memory cell is coupled to a reference voltage signal that is greater than a reference
3 voltage signal coupled to at least one of the emitter regions of the thyristors in the plurality of
4 memory cells.

1 13. The memory device of claim 11, wherein an emitter of the thyristor in the first
2 reference memory cell is coupled to a reference voltage signal that is less than a reference
3 voltage signal coupled to at least one of the emitter regions of the thyristors in the plurality of
4 memory cells.

1 14. The memory device of claim 11, wherein each memory cell includes a pass device
2 coupled to an emitter region of the respective thyristor, each pass device exhibiting leakage,
3 the pass device in the second reference thyristor memory cell being adapted to leak relatively
4 more current than the pass devices in the plurality of memory cells such that the second
5 reference memory cell fails to retain data before the plurality of memory cells fail to retain
6 data.

1 15. The memory device of claim 6, wherein the second control port and the second base
2 region are configured and arranged such that the second signal increases carrier depletion in
3 the second base region in the second base region.

1 16. The memory device of claim 6, wherein the second control port extends over a junction
2 between the second base region and the second emitter region.

- 1 17. The memory device of claim 16, wherein the second circuit is adapted to capacitively
2 couple the second signal to the second emitter region for accumulating carriers therein.
- 1 18. The memory device of claim 6, wherein the second control port extends over a junction
2 between the first and second base regions.
- 1 19. A semiconductor device comprising:
2 a thyristor having thyristor body regions including first and second immediately
3 adjacent base regions between first and second emitter regions, the thyristor body being
4 maintained in a conductance state as a function of holding current; and
5 a control circuit configured and arranged for applying a signal to at least one of the
6 base regions for controlling the holding current or forward blocking voltage as a function of
7 temperature.
- 1 20. The semiconductor device of claim 19, wherein the thyristor is a thin capacitively-
2 coupled thyristor.
- 1 21. The memory device of claim 6, wherein the thyristor is a thin capacitively-coupled
2 thyristor.
- 1 22. The memory device of claim 1, wherein the thyristor is a thin capacitively-coupled
2 thyristor.
- 1 23. The memory device of claim 1, wherein one of the base regions includes N-doped
2 material having a higher concentration of N⁺ dopant in a depletion region that faces the
3 second control port.
- 1 24. The memory device of claim 1, wherein one of the base regions includes material
2 having defects in a depletion region facing the second control port.
- 1 25. The memory device of claim 6, wherein one of the base regions includes N-doped
2 material having a higher concentration of N⁺ dopant in a depletion region that faces the
3 second control port.

1 26. The memory device of claim 6, wherein one of the base regions includes material
2 having defects in a depletion region facing the second control port.

1 27. The semiconductor device of claim 19 further comprising a second control port,
2 wherein one of the base regions includes N-doped material having a higher concentration
3 of N⁺ dopant in a depletion region that faces the second control port.

1 28. The semiconductor device of claim 19 further comprising a second control port,
2 wherein one of the base regions includes material having defects in a depletion region
3 facing the second control port.